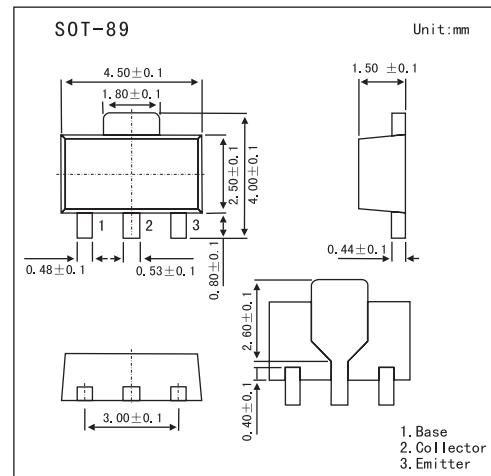


NPN Epitaxial Planar Silicon Transistors

2SC4080



■ Features

- High F_t
- High breakdown voltage
- Small reverse transfer capacitance excellent high-frequency characteristic
- Adoption of FBET process

■ Absolute Maximum Ratings $T_a = 25^\circ\text{C}$

Parameter	Symbol	Rating	Unit
collector-base voltage	V_{CBO}	200	V
collector-emitter voltage	V_{CEO}	200	V
emitter-base voltage	V_{EBO}	4	V
collector current	I_C	100	mA
Collector Current (pulse)	I_{CP}	200	mA
Collector Dissipation	P_C	500	mA
		1.3	W
junction Temperature	T_J	150	$^\circ\text{C}$
storage Temperature	T_{stg}	-55 to 150	$^\circ\text{C}$

*Mounted on ceramic board (250mm²X0.8mm)

2SC4080

■ Electrical Characteristics Ta = 25°C

Parameter	Symbol	Testconditons	Min	Typ	Max	Unit
collector cutoff Current	I _{CBO}	V _{CB} =150V,I _E =0			0.1	µA
Emitter cutoff current	I _{EBO}	V _{EB} =2V,I _C =0			1.0	µA
DC Current Gain	h _{FE}	V _{CE} =10V,I _C =10mA	40		320	
		V _{CE} =10V,I _C =100mA	20			
Gain-Bandwidth product	f _T	V _{CE} =30V,I _C =30mA		400		MHz
Output Capacitance	C _{OB}	V _{CB} =30V,f=1MHz		1.8		pF
Reverse Transfer	C _{RE}	V _{CB} =30V,f=1MHz		1.4		
Collector to Emitter Saturation Voltage	V _{CE(sat)}	I _C =20mA,I _B =2mA			1	V
Base to Emitter Stauration Voltage	V _{BE(sat)}	I _C =20mA,I _B =2mA			1	V
Collector to Base Breakdown Voltage	V _{(BR)CBO}	I _C =10µA,I _E =0	200			V
Collector to Emitter Breakdown Voltage	V _{(BR)CEO}	I _C =1mA,I _B =0	200			V
Emitter to Base Breakdown Voltage	V _{(BR)EBO}	I _E =100µA,I _C =0	4			V

■ hFE Classification

Marking	CI			
	Rank	C	D	E
Type	40 to 80	60 to 120	100 to 200	160 to 320